

Electronic Acknowledgement Receipt

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Application Number:	10599440
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Confirmation Number:	8901
Title of Invention:	Silicon electrode plate for plasma etching with superior durability
First Named Inventor/Applicant Name:	Hideki Fujiwara
Customer Number:	07278
Filer:	Kenneth B. Ma/Lillian Garcia
Filer Authorized By:	Kenneth B. Ma
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)/ Message Digest	Multi Part /.zip	Pages (if appl.)
1	Transmittal Letter	IDS.PDF	84311 <small>etced8b65c1d47b0cde659133e72579cdaa56</small>	no	4

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2	NPL Documents	JP_OA.PDF	173528 56da96937194f263634e85c68f5952d8f85e	no	5
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3	Information Disclosure Statement (IDS) Filed (SB/08)	SB08.PDF	610298 f5015d9dc3b3d8cc900a6761f79287a7e62	no	4
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4	Foreign Reference	JP2002-299345.PDF	281644 8f4661b29963a68f764f65858775c11128f53d4	no	5
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5	Foreign Reference	JP2003-137687.PDF	275624 48aa94d173ed4c3039d5c94e05585d6706ba	no	6
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